

L Number	Hits	Search Text	DB	Time stamp
8	2884	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 (water H2O ("H.sub.2" adj "O")))	USPAT; US-PGPUB	2002/10/31 19:39
9	1623	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 (water H2O ("H.sub.2" adj "O")))	EPO; JPO; DERWENT; IBM_TDB	2002/10/31 19:32
12	589	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 ((hydrogen H2 "H.sub.2") near5 (oxygen O2 "O.sub.2")))	USPAT; US-PGPUB	2002/10/31 19:34
10	57	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 ((hydrogen H2 "H.sub.2") near5 (oxygen O2 "O.sub.2")))	EPO; JPO; DERWENT; IBM_TDB	2002/10/31 19:34
13	2496	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 (water H2O ("H.sub.2" adj "O")) and (metal conduct\$3)	USPAT; US-PGPUB	2002/10/31 19:38
14	169	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 (water H2O ("H.sub.2" adj "O")) near100 (ammonia NH3 "NH.sub.3"))	USPAT; US-PGPUB	2002/10/31 19:41
15	74	((remov\$3 etch\$3 dehash\$3 strip\$4) near100 (photoresist resist PR photo?reist) near100 (water H2O ("H.sub.2" adj "O")) near100 (nitrogen N2 "N.sub.2"))	USPAT; US-PGPUB	2002/10/31 19:43